AMENDMENTS TO THE CLAIMS:

This listing of claims will replace all prior versions, and listings, of claims in the application:

LISTING OF CLAIMS:

1-53. (canceled)

54. (currently amended) An active matrix addressing LCD device comprising:

an active matrix substrate having a transparent, dielectric plate, thin film transistors (TFTs) arranged on the plate, and pixel electrodes arranged on the plate;

wherein the active matrix substrate includes at least one of scan lines, signal lines, and common lines, each of the lines having a multilevel conductive structure at a respective terminal thereof; [[and]]

wherein the multilevel conductive structure comprises a TiN film having a nitrogen concentration of 25 atomic % or higher, the TiN film being located at a top of the multilevel conductive structure; and

wherein a transparent conductive film is absent from the TiN film.

55. (previously presented) The device according to claim 54, wherein the multilevel conductive structure comprises

an Al-based film located below the TiN film, and at least one Ti film located at least at one of an upper position and a lower position with respect to the Al-based film.

- 56. (new) The device according to claim 55, wherein each of the lines has a same multilevel conductive structure not only at the respective terminal, but also in the remaining parts thereof.
- 57. (new) The device according to claim 55, wherein the multilevel conductive structure is a three-level structure formed by the TiN film located at the top, the Ti film located at the middle, and the Al-based film located at the bottom.
- 58. (new) The device according to claim 55, wherein the multilevel conductive structure is a three-level structure formed by the TiN film located at the top, the Al-based film located at the middle, and the Ti film located at the bottom.
- 59. (new) The device according to claim 55, wherein the multilevel conductive structure is a four-level structure formed by the TiN film located at the top, the Ti film located at the upper middle, the Al-based film located at the lower middle, and the Ti film located at the bottom.
- 60. (new) The device according to claim 55, wherein the Al-based film is made of Al, or an Al alloy including Al as its main ingredient.